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Amendments to the Claims

This listing of claims replaces all prior versions and listings of claims in the application.

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## Listing of Claims

- 1-20. (Canceled)
- (Currently Amended) A personal computer comprising:

a semiconductor film provided over a substrate and comprising a source region, a drain region and a channel formation region provided between said source region and said drain region: and

a gate electrode provided adjacent to said channel formation region with a gate insulating film therebetween,

wherein lattices are continuously connected to each other at a grain boundary of said semiconductor film between different crystals, [[and]]

wherein atoms constituting the different crystals at the grain boundary correspond to each other respectively or have dangling bonds neutralized by hydrogen or halogen elements, and

wherein a halogen element is contained in said semiconductor film with a concentration of  $1 \times 10^{15}$  to  $1 \times 10^{20}$  atoms/cm<sup>3</sup>.

- (Previously Presented) A computer according to claim 21 further comprising an auxiliary capacitance.
  - (Previously Presented) A computer according to claim 21 further comprising:
     a pixel electrode;
  - an opposite electrode; and
  - a liquid crystal provided between said pixel electrode and said opposite electrode.

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24. (Canceled)

 (Previously Presented) A computer according to claim 21 wherein a channel length of said channel formation region is 2 um or shorter.

26-41. (Canceled)

- 42. (Previously Presented) A computer according to claim 21 wherein a direction of movement of a carrier in said channel formation region coincides with a direction of extension of said grain boundary.
- (Previously Presented) A computer according to claim 21 wherein the semiconductor film comprises silicon.
- (Previously Presented) A computer according to claim 21 wherein the semiconductor film comprises a rod-shaped crystal.
- (Previously Presented) A computer according to claim 21 wherein the semiconductor film comprises a flattened rod-shaped crystal.
- (Previously Presented) A computer according to claim 23 wherein the pixel electrode comprises ITO.
  - 47. (Currently Amended) A personal computer comprising:
- a semiconductor film provided over a substrate and comprising a source region, a drain region and a channel formation region provided between said source region and said drain region; and
- a gate electrode provided adjacent to said channel formation region with a gate insulating film therebetween, and
  - a thermal oxidation film provided between the semiconductor film and the gate electrode,

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wherein lattices are continuously connected to each other at a grain boundary of said semiconductor film between different crystals, [[and]]

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wherein atoms constituting the different crystals at the grain boundary correspond to each other respectively or have dangling bonds neutralized by hydrogen or halogen elements, and

wherein a halogen element is contained in said semiconductor film with a concentration of 1 x 10<sup>15</sup> to 1 x 10<sup>20</sup> atoms/cm<sup>3</sup>.

- 48. (Previously Presented) A computer according to claim 47 further comprising an auxiliary capacitance.
  - (Previously Presented) A computer according to claim 47 further comprising:
     a pixel electrode:

an opposite electrode; and

- a liquid crystal provided between said pixel electrode and said opposite electrode.
- (Previously Presented) A computer according to claim 47 wherein a channel length of said channel formation region is 2 μm or shorter.
- 51. (Previously Presented) A computer according to claim 47 wherein a direction of movement of a carrier in said channel formation region coincides with a direction of extension of said grain boundary.
- (Previously Presented) A computer according to claim 47 wherein the semiconductor film comprises silicon.
- (Previously Presented) A computer according to claim 47 wherein the semiconductor film comprises a rod-shaped crystal.

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 (Previously Presented) A computer according to claim 47 wherein the semiconductor film comprises a flattened rod-shaped crystal.

- (Previously Presented) A computer according to claim 49 wherein the pixel electrode comprises ITO.
  - 56. (Currently Amended) A personal computer comprising:

a semiconductor film provided over a substrate and comprising a source region, a drain region, a channel formation region provided between said source region and said drain region, and a low concentration impurity region provided between the channel formation region and at least one of the source region and the drain region; and

a gate electrode provided adjacent to said channel formation region with a gate insulating film therebetween.

wherein lattices are continuously connected to each other at a grain boundary of said semiconductor film between different crystals. [[and]]

wherein atoms constituting the different crystals at the grain boundary correspond to each other respectively or have dangling bonds neutralized by hydrogen or halogen elements, and

wherein a halogen element is contained in said semiconductor film with a concentration of 1 x 10<sup>15</sup> to 1 x 10<sup>70</sup> atoms/cm<sup>3</sup>.

- (Previously Presented) A computer according to claim 56 further comprising an auxiliary capacitance.
  - (Previously Presented) A computer according to claim 56 further comprising:
     a pixel electrode;

an opposite electrode; and

- a liquid crystal provided between said pixel electrode and said opposite electrode.
- (Previously Presented) A computer according to claim 56 wherein a channel length of said channel formation region is 2 µm or shorter.

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60. (Previously Presented) A computer according to claim 56 wherein a direction of movement of a carrier in said channel formation region coincides with a direction of extension of said grain boundary.

- 61. (Previously Presented) A computer according to claim 56 wherein the semiconductor film comprises silicon.
- 62. (Previously Presented) A computer according to claim 56 wherein the semiconductor film comprises a rod-shaped crystal.
- 63. (Previously Presented) A computer according to claim 56 wherein the semiconductor film comprises a flattened rod-shaped crystal.
- 64. (Previously Presented) A computer according to claim 58 wherein the pixel electrode comprises 1TO.
  - 65-67. (Canceled)
- 68. (Previously Presented) A personal computer according to claim 21 wherein said substrate comprises a silicon wafer.
- 69. (Previously Presented) A personal computer according to claim 47 wherein said substrate comprises a silicon wafer.
- 70. (Previously Presented) A personal computer according to claim 56 wherein said substrate comprises a silicon wafer.